

Generation of copper nanoparticles induced by fs-laser irradiation in borosilicate glass

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Outline

- Why obtain nanoparticles in glass?
- Why using fs-laser micromachining?
- Goal
- Material and methods
- Results
- Conclusions

Why obtain nanoparticles in glass?

- Local field enhancement effect
- They are promising materials for photonic applications once they can exhibit ultrafast response times and high third order nonlinearities

Why using fs-laser micromachining?

Advantages:

- Spatial control of the nanoparticles formation in the micrometer scale;
- Obtaining metallic nanoparticles in confined regions at the surface or into the bulk of the materials;
- Development of photonic devices with high third order nonlinearities and ultrafast response times;



The purpose of this study was to produce and control copper nanoparticles at small regions on the surface and inside a borosilicate glass

Material



(50SiO₂ - 17B₂O₃ - 11,5MgO - 10Na₂O - 11,5 Al₂O₃):0,1CuO



Micromachining set up







Absorption spectrum of the copper doped borosilicate glass as prepared (curve A), and after the fs-laser irradiation in the bulk using NA = 0.65, v = 100 μ m/s, E = 92 μ J (curve B).

Transmission electron microscopy and electron diffraction



Metallic nanoparticles formation



Self-focusing effect

It is a consequence of the intensity-dependent refractive index - Kerr optical effect, $n = n_0 + n_2 I$

Self-focusing Self-focusing occurs when a nonuniform intensity distribution propagates through a material with positive nonlinear refractive index. Propagation direction Material Wavefront aser direction

Side view of the microstructure

50 µm

Optical Kerr effect

 $n = n_0 + n_2 I$ $n_2 = 3.10^{-20} \text{ m}^2/\text{W}$ at 775 nm



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Copper nanoparticles on glass surface



Absorption and scattering coefficient (K/S) spectra obtained from diffuse reflectance, of the sample as prepared (curve A), and after irradiation (NA = 0.25, E = 258 μ J, v = 1000 μ m/s) and further annealing at 570° C/1h (curve B)

The influence of the experimental parameters

Irradiation position	Microscope objective	Laser scanning speed (µm/s)	Annealing (°C)	Surface Plasmon Resonance band
Surface	NA = 0.25	1000	570	Yes 🝪
Bulk	NA = 0.25	1000	570	No
Bulk	NA = 0.65	100	600	Yes 🔅

We have suggest that there is an optimal combination among the experimental parameters so that the grown of the nanoparticles may happen.





- We have shown the formation of copper nanoparticles in the bulk and on the surface of the copper doped borosilicate glass by femtosecond laser irradiation and further annealing.
- The size of the nanoparticles is around 9 nm, and they are composed by metallic copper atoms.
- Slower scan speed, higher intensity of the laser beam and higher heating temperature favors the nanoparticle formation process.
- A preferential accumulation of the nanoparticles in the bottom region of the microstructure was observed due to a self-focusing effect.

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